

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Applicants : Tokumi KOBAYASHI  
T. C. Art Unit : 2123  
Appl. No. : 10/596,088 (National Stage  
of PCT/JP2004/017467)  
Examiner : S. S. Rao  
I. A. Filed : November 25, 2004  
Confirmation No. : 1724  
For : CIRCUIT SUBSTRATE PRODUCTION METHOD AND SYSTEM,  
SUBSTRATE USED THEREIN, AND CIRCUIT SUBSTRATE USING  
THE SAME

**RESPONSE UNDER 37 C.F.R. § 1.116**

Commissioner for Patents  
U.S. Patent and Trademark Office  
Customer Service Window, Mail Stop AF  
Randolph Building  
401 Dulany Street  
Alexandria, VA 22314

Sir :

In response to the Final Official Action dated August 17, 2009, setting a three month period for response until November 17, 2009, Applicant respectfully requests reconsideration and withdrawal of the outstanding rejections, as well as an indication of the allowability of all of the claims pending in the present application.

Should an extension of time by necessary to maintain the pendency of the present application, including extensions of time to place the present application in condition for allowance by an Examiner's Amendment, the Commissioner is hereby authorized to charge any additional fee to Deposit Account No. 19-0089.

**Remarks/Arguments** begin on page 2 of this response.